

## Tunnel magnetoresistance in ultrathin MnGa-based perpendicular magnetic tunnel junctions utilizing bcc-Co based interlayers

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Tetragonal Mn-based perpendicular magnetic tunnel junctions (p-MTJs) attracts attention for magnetic random access memory and advanced THz devices<sup>1</sup>. Past studies of Mn-based p-MTJs have been reported small TMR ratio at room temperature below 32% without magnetic interlayer<sup>2</sup>, and maximum of 60% even if FeCo interlayers were used<sup>3</sup>. Thus, it is crucial to find new interlayer materials to further enhance the TMR ratio for realizing Mn-based p-MTJs for practical applications. In this study, we focused on bcc-CoMn binary alloy possessing highly spin-polarized  $\Delta 1$  band<sup>4</sup> as new interlayer material for ultrathin MnGa-based p-MTJs<sup>5</sup>, and investigated its TMR properties<sup>6</sup>. The stacking structure of the p-MTJs are MgO(001) substrate/Cr(40)/Co<sub>55</sub>Ga<sub>45</sub>(30)/ Mn<sub>61</sub>Ga<sub>39</sub>(3)/ Co<sub>x</sub>Mn<sub>100-x</sub>(0.8) /Mg(0.4)/MgO(2)/ Fe<sub>60</sub>Co<sub>20</sub>B<sub>20</sub>(1.2)/Ta(3)/Ru(5) (thickness is in nanometers). After microfabrication using conventional photolithography and Ar ion milling process, the MTJs were annealed at 250 °C in a vacuum furnace. TMR measurements were performed by a PPMS. Figure 1 shows the TMR curves of the MTJs with Co<sub>80</sub>Mn<sub>20</sub> interlayer measured at 300 and 10 K. The Co<sub>80</sub>Mn<sub>20</sub> interlayer shows the TMR ratio up of approximately 85% (209%) at 300 and 10 K, respectively. Meanwhile, the shape of the TMR curve and the significant increase of coercivity indicate that Co<sub>80</sub>Mn<sub>20</sub> interlayer strongly and antiferromagnetically couples with perpendicularly-magnetized MnGa layer. The TMR ratio of 209% is larger than the value expected from Julliere's relation with spin-polarization of fcc-Co and CoFe(B). Thus, this high TMR ratio would originate from coherent tunneling between highly spin-polarized  $\Delta 1$  bands in bcc-Co (Co-Mn) and CoFe(B) electrodes, even though the Co-Mn interlayer thickness is very small, 0.8 nm.

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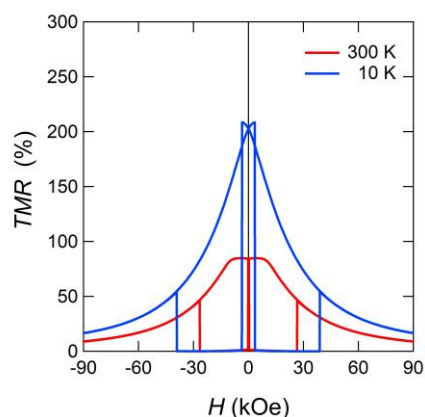


Figure1 TMR loops the MTJs with Co<sub>80</sub>Mn<sub>20</sub> interlayer measured at 300 K and 10 K